The proposal of spin-polarized current-induced magnetization dynamics of Slonczewski\(^1\) and Berger\(^2\) initiated a lot of theoretical and experimental studies in the last years. Promising applications have been found in spin-torque magnetic random access memory and spin torque nano-oscillators (STNOs). The latter shows a steady precession of the magnetization of the free layer under the action of a spin-polarized dc current. Via the giant magnetoresistance or tunnel magnetoresistance (GMR or TMR) effect this precession generates a high-frequency (HF) voltage oscillation with frequencies in the GHz range and a rather wide tuning range by dc current and external magnetic field. Still, one drawback of STNOs is their low output power. To achieve useful power levels several groups work on the synchronization of arrays of STNOs.\(^3\)\(^-\)\(^5\) While this is a very promising approach, maximizing the output power of every single STNO is undeniably the first step to do.

There are several possible arrangements for STNOs. In-plane magnetized free and fixed layers with in-plane,\(^6\) or out-of-plane external fields,\(^7\) in-plane magnetized free and perpendicularly magnetized fixed layers,\(^8\) and free layer magnetized in a vortex state with in-plane magnetized fixed layer,\(^9\)\(^-\)\(^10\) have been studied experimentally. Comparing the characteristics—especially output power—of HF excitations of these arrangements from different experiments is not conclusive, because impedance and absolute resistance change, \(\Delta R = R_{AP} - R_P\), of the samples have a very strong influence on the detected power. Here, we study HF excitations in two of the arrangements mentioned above that we are able to realize in the same sample. While the fixed layer is uniformly in-plane magnetized, the free layer is either uniformly in-plane magnetized or in a vortex state. The direct comparison shows some advantages of the vortex state for the application in STNOs.

The samples are fabricated by depositing 150 nm Ag/2 nm Fe/6 nm Ag/20 nm Fe/50 nm Au by molecular beam epitaxy on a cleaned and annealed GaAs(100) substrate. All layers grow epitaxially as is confirmed by \textit{in situ} low-energy electron diffraction measurements. The Fe layers adopt a bcc structure, which yields a cubic magnetocrystalline anisotropy. Bottom electrodes are formed using optical lithography and ion beam etching (IBE). Then the nanopillars are defined by electron beam lithography and IBE. The pillars have a circular cross-section with a diameter of approximately 230 nm. Only the top magnetic layer is laterally confined, while the bottom layer is left extended on the bottom electrode (with a typical width of 15 \(\mu\)m). We control this step by probing the bottom electrodes with magneto-optical Kerr effect measurements. The pillar is then insulated and the sample surface planarized by spinning on a flowable oxide (fOx-12) of approximately 200 nm thickness and by depositing 50 nm silicon nitride by plasma-enhanced chemical-vapor deposition. The insulation is removed in small areas above the pillars by IBE and reactive ion beam etching until the pillar tips are uncovered. Finally, Ti 15 nm/Au 200 nm top electrodes are formed by optical lithography, thermal evaporation, and lift-off technique.\(^11\) Using this process we fabricate nanomagnets of 230 nm diameter and 20 nm thickness, which are separated by 6 nm Ag from an extended 2-\(\mu\)m-thick Fe layer [see inset in Fig. 1(a)]. The dimensions of the nanomagnets are in a regime where a magnetic vortex structure and a uniform in-plane magnetization are both stable states.\(^12\) The 2-\(\mu\)m-thick extended layer, on the other hand, will be uniformly magnetized on length scales much larger than the pillar diameter as long as there is at least a small magnetic field suppressing domain formation.

Micromagnetic simulations were performed using a custom-developed finite-element algorithm. In this algorithm, magnetostatic fields are calculated with a combined finite-element/boundary element method as already used in previous studies.\(^13\) The usual values for Fe material parameters were chosen: saturation magnetization \(\mu_0M_S = 2.15\) T, cubic anisotropy \(K_u = 48\) kJ/m\(^3\), exchange constant \(A = 2.1 \times 10^{11}\) J/m, and a value of \(\alpha = 0.01\) for the Gilbert damping constant.

First we characterize the GMR response by measuring the pillar resistance at 10 K while sweeping a magnetic field. We apply a dc current of 1 mA and measure the voltage drop in a four-probe geometry. Figure 1(a) shows a GMR curve, where the magnetic field was aligned in the sample plane and

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parallel to a magnetic easy axis of the Fe layers. Differences to a field sweep parallel to a hard axis are not significant indicating that anisotropy does not play an important role. Starting from saturation at −150 mT a steep increase in the resistance can be seen at −70 mT. The increase slows down until a plateau of maximum resistance is reached with a small step at a reversed field of +5 mT. At +20 mT the resistance shows a sudden drop to a level of 1.040, which appears after field reversal [+10 mT in Fig. 1(b)]. The formation of the vortex results in a zero-mean in-plane magnetization. The current-perpendicular-plane GMR in Fe/Ag/Fe layers shows a specific angular dependence due to spin accumulation. This results in a drop of the normalized resistance to the experimentally observed value \( r = 0.25 \).

Upon further increasing the external field, the vortex core is moved from the center of the disk to the rim [+80 mT in Fig. 1(b)] until it is expelled at about +200 mT. The simulations qualitatively reproduce the experimental results; quantitative differences of the switching fields most likely arise from reduced magnetization and exchange constant in the nanomagnet as well as from the differences between the simulated and the experimental systems.

In order to keep the computational effort in reasonable bounds, the simulations include only a thin magnetic nanodisk, while in the experiment the thin magnetic layer is extended. Since most of the stray field originates from the thick nanomagnet this approximation should only give minor discrepancies between experiment and simulation. The most obvious difference is that in the simulation the magnetization direction of the thick nanomagnet aligns opposite to the direction of the external field because it has less magnetic moment than the thick nanomagnet. In the experiment, however, it is more likely that the magnetization direction of the thick nanomagnet is turning, since the relevant part of the thin, extended magnetic layer is stabilized by the exchange interaction to the rest of the micron-sized layer. The notable plateau in the measured resistance curve between +5 and +20 mT is not explained by the micromagnetic simulations. We assume that at +5 mT the vortex nucleates in the nanomagnet, and at the same time the reversal of the extended layer happens via domain-wall formation and motion. This may result in a highly nonuniform magnetization state in the extended layer leading to the resistance plateau. At +20 mT the magnetization in the extended layer is finally reversed and homogeneous yielding a lowered resistance.

Having characterized the behavior of the system in response to externally applied fields, we now address current-induced switching processes by sweeping the dc current from 0 to 25 mA, then to −25 mA and back to 0 mA at fixed magnetic fields. The initial states were prepared by magnetic field sweeps from positive or negative saturation to the stated field values. Measurements were performed at 10 K. Figure 2 shows the evolution of current-induced switching for different strengths of the magnetic field that was applied parallel to a magnetic easy axis. At 40 and 49 mT full hysteretic switching can be seen (green and red curves), where at positive currents a high-resistive state and at negative currents a low-resistive state is reached. Results depicted in Fig. 1 supports the conclusion that the switching events take place in the nanomagnet rather than the thinner extended reference layer. In our convention, a positive current corresponds to an electron flow from the nanomagnet to the extended layer. In
previous experiments with Fe/Ag/Fe pillars\textsuperscript{14,15,16} we have established that the spin-transfer torque due to a positive current acts toward an antiparallel alignment. Therefore, the high-resistive state can be identified in terms of antiparallel aligned uniform magnetizations and the low-resistive state as the vortex state. The two resistance values near 0 mA of the unshifted green curve in Fig. 2 measured at 49 mT indeed correspond to the values of the red and blue curves at +49 mT in Fig. 1. This interpretation also correlates well with the observed shift of the hysteresis to the left when the magnetic field is increased. The vortex state is less favorable for higher fields than the uniform state. Therefore the switching to the vortex state at negative currents is getting harder. On the other hand, the two graphs recorded at 30 mT (blue and black curves) show that at this weaker field, a switching to the uniform state is no longer possible with currents up to 25 mA corresponding to $6 \times 10^{11}$ A/m$^2$. Simultaneously the magnitude of the critical current for switching from the uniform state to the vortex state is decreasing. For the black curve at 30 mT and the purple one at 40 mT the measurement started from the uniform state. The fact that we do not observe a switching to the vortex state at positive currents in these measurements shows that the prevalent torque in the switching processes does not originate from Oersted fields. These circumferential fields tend to switch the magnetization of the nanomagnet into a vortex state also at positive currents, just with the opposite vorticity compared to negative currents.

We measure dc current-induced HF excitations of the magnetization at room temperature by amplification and detection of voltage oscillations across the nanopillar using a microwave probe station. The voltage variation arises from the GMR of the Fe/Ag/Fe stack, which reaches 2\% or 22 m\Omega in Fig. 1(a). The impedance of our sample was 11 \Omega at 1.5 GHz. Figure 3(a) shows the HF response of a nanopillar with magnetization in the uniform state measured in an external field of 82 mT applied along an easy axis of the Fe layers. The observed behavior is qualitatively similar for other field values. We are able to detect this excitation between 35 and 82 mT with maximum frequencies only slightly increasing from 1.67 to 1.78 GHz. In the shown case, at a threshold current of 27 mA a weak signal appears at 1.762 GHz. The amplitude and frequency increase slightly with increasing current up to 1.783 GHz at 32 mA, i.e., the observed mode is blueshifting in this current range. At 32 mA the peak width reaches a minimum of 8 MHz. For further increasing current the frequency redshifts to 1.739 GHz at the maximum applied current of 40 mA while the peak broadens to 11 MHz. The mode agility in this regime is about 6 MHz/mA. A maximum power of 3.2 pW/(GHz mA$^2$) is reached at a current of 36 mA.

The low frequencies of the excitations are a result of the cancellation of the dipolar coupling field of about 80 mT by the external field. We assume a standing-wave mode, where the rather large size of the element leads to low-frequency excitations, too. The observed blueshift behavior at low currents can be interpreted in terms of such a standing-wave mode; measurement at 82 mT. (b) The gyrotropic mode is excited after preparation of the vortex state; measurement at 25 mT. Note that the microwave output power generated by the gyrating vortex for a given dc current in (b) is much higher than for the standing-wave mode in (a).
early from 1.38 to 1.65 GHz is measured. The resulting mode agility is +17 MHz/mA. The smallest linewidth of 14 MHz is achieved at 32 mA. The maximum power of 9.3 pW/(GHz mA²) is reached at a current of 34 mA. At some values of the current two peaks are present, thus showing a mode-hopping behavior. This vortex excitation is only present in small fields from 10 up to 42 mT and shows a frequency increase from 1.52 to 1.72 GHz with increasing field. A comparison of the most relevant characteristics for the two states is compiled in Table I.

Here, the gyrotropic mode of the vortex is excited as previously reported by Pribiag et al. There is a significant difference in the HF excitations observed for the same nanopillar with magnetization in the uniform state. This difference is caused by the strongly inhomogeneous magnetization pattern of the magnetic vortex. The current exerts spin-transfer torque on the vortex in such a way that the vortex core is moved from its equilibrium position in the center of the nanodisk, but the internal structure of the vortex does not change. As a result the vortex starts a circular motion around the equilibrium position. If a steady spin-transfer torque excitation acts on the vortex, it will find a stable elliptic or circular trajectory with a radius proportional to the excitation amplitude. When for increasing current the trajectory approaches the rim of the disk, the vortex experiences a stronger restoring force, increasing its precessional frequency. This results in a linear increase in the frequency yielding a linear mode agility of +17 MHz/mA [Fig. 3(b)]. An in-plane magnetic field will move the center of the vortex gyration to the rim of the disk, thus also leading to an increase in frequency. This dynamic mode is described by the movement of a rigid magnetic structure or particle rather than by a standing-wave pattern as is the case for the uniform state. At each spot within the trajectory of the vortex core, the magnetization rotates during one period of the gyrotropic cycle by full $2\pi$ about the sample normal. Thus, for a vortex core moving on a trajectory close to the rim of the sample the product of oscillation amplitude times area, where oscillations take place, is maximized. As a consequence, the emitted power of the nanopillar in the vortex state is nearly three times the power emitted in the uniform state (Fig. 3 and Table I).

We studied HF excitations of a vortex and a uniform state in the same sample. Due to negligible variation in the sample impedance over the explored frequency range, we can directly compare the output power and other properties of the excitations. Higher agility, wider tuning range, and higher output power are all advantageous for the application of the vortex state in STNOs, while a lower linewidth is achieved in the uniform state. Although this conclusion is derived from metallic, GMR-type STNOs, our generic, micromagnetic arguments make it valid also for TMR-based STNOs, which intrinsically generate higher output power.

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**TABLE I.** Comparison of most relevant characteristics of the HF excitations of uniform and vortex states. The minimal critical current for the uniform state is 19 mA at an in-plane magnetic field of 48 mT.

<table>
<thead>
<tr>
<th>Free layer in:</th>
<th>Uniform state</th>
<th>Vortex state</th>
</tr>
</thead>
<tbody>
<tr>
<td>Min. Critical current density (10¹¹ A/m²)</td>
<td>4.6</td>
<td>4.8</td>
</tr>
<tr>
<td>Agility (MHz/mA)</td>
<td>6</td>
<td>17</td>
</tr>
<tr>
<td>Spanned freq. range (MHz)</td>
<td>44</td>
<td>270</td>
</tr>
<tr>
<td>Max. power [pW/(GHz × mA²)]</td>
<td>3.2</td>
<td>9.3</td>
</tr>
<tr>
<td>Min. linewidth (MHz)</td>
<td>8</td>
<td>14</td>
</tr>
</tbody>
</table>